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MICROSCOPE, ESPECIALLY MICROSCOPE USED FOR INSPECTION IN  
SEMICONDUCTOR MANUFACTURE

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CROSS-REFERENCE TO RELATED APPLICATIONS

This application claims priority of International Application  
No. PCT/EP00/09199, filed September 20, 2000 and German Application  
10 No. 199 46 594.0, filed September 29, 1999, the complete disclosures of which are  
hereby incorporated by reference.

BACKGROUND OF THE INVENTION

15 Field of the Invention

The invention is directed to the coupling of pulsed laser radiation into  
a microscope, especially a microscope used for the quality control and classification  
of defects of masks for the manufacture of semiconductors.

20 SUMMARY OF THE INVENTION

In accordance with the invention, a microscope, especially for use  
during inspection in semiconductor manufacture comprising a pulsed laser for  
illumination, the laser being preferably in the UV range. The microscope includes  
at least one rotating diffusion disk which is arranged behind the laser for the  
25 homogenization of the illumination

BRIEF DESCRIPTION OF THE DRAWINGS

In the drawings:

30 Figure 1 shows an overall diagrammatic view of an inspection device  
using a microscope in accordance with the invention;

Figure 2a shows a diagram of a coupling unit for coupling the laser  
beam into the microscope; and

## DESCRIPTION OF THE PREFERRED EMBODIMENTS

Figure 1 shows an overall diagrammatic view of an inspection device consisting of a laser module LM with a pulsed UV laser, a transmitter port UP, a microscope MI with an objective O and a scanning table ST, a CCD camera KA, a screen BS and a microscope controller MC.

The laser light reaches a first rotating diffusion disk S1 via reflecting mirrors U1, U2 and then a second rotating diffusion disk S2 preferably rotating in the opposite direction as well as the microscope ray path (not shown) via a lens for beam expansion and an aperture B and the input E in Figure 1 and illuminates the object to be examined.

The diffusion disk rotates at a speed which is relatively low when compared to the spacing of two laser pulses.  $\leftarrow$  8

This has the advantage of averaging out the granularity of the diffusion disk and furthermore that the granularity caused by the coherence of the laser radiation (speckle) is also averaged out.

Note

For this, the magnitude of the rotating speed of the diffusion disk can lie in the easily realized range of approximately 1 rotation per second (a speed in the range of cm/s), so that for an assumed grain size of 0.1mm a displacement by at least the size of one grain takes place between two pulses.

5 The homogenizing effect is reinforced by a second diffusion disk rotating in the opposite direction.

Besides granulated diffusion disks (made by etching or abrasive blasting), holographic disks can also be used.

10 CGHs (computer-generated holograms) can also be used for homogenization.

While the foregoing description and drawings represent the present invention, it will be obvious to those skilled in the art that various changes may be made therein without departing from the true spirit and scope of the present invention.

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